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A Simple Base-Mediated Halogenation of Acidic sp² C—H Bonds under Noncryogenic Conditions

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ABSTRACT

A new method has been developed for in situ halogenation of acidic sp² carbon—hydrogen bonds in heterocycles and electron-deficient arenes. Either selective monohalogenation or one-step exhaustive polyhalogenation is possible for substrates possessing several C—H bonds that are flanked by electron-withdrawing groups. For the most acidic arenes, such as pentafluorobenzene, K₃PO₄ base can be employed instead of BuLi for metalation/halogenation sequences.

We have recently developed a method for copper-catalyzed arylation of sp² C—H bonds possessing DMSO pK_a's below 35.¹ The reaction was shown to proceed via an aryllithium or arylpotassium intermediate that is formed in situ by the reaction of the arene with either K₃PO₄ or *t*BuOLi metalating agent (Scheme 1A). It occurred to us that halogenation of arenes that are reactive under the copper-catalyzed arylation conditions should be possible under mild nucleophilic conditions by employing relatively weak bases such as K₃PO₄ or *t*BuOLi (Scheme 1B). Current methods for halogenation of electron-deficient arenes such as polyfluoro- or polychlorobenzenes involve either harsh electrophilic conditions or the use of strong alkyllithium bases and cryogenic conditions.² If the positive halogen source would form an

Scheme 1. Functionalization of Acidic sp² C-H Bonds

1B. Ar-H
$$\stackrel{\text{K}_3PO_4 \text{ or } t\text{BuOLi}}{\longleftarrow}$$
 Ar-M $\stackrel{\text{E}^{\bigoplus}}{\longleftarrow}$ Ar-E

active halogenating agent in the reaction with base, an in situ trapping of the arylmetal species should be possible. Martin has reported use of a strong LiTMP base for in situ deprotonation/silylation of aromatic nitriles, esters, and pyridine derivatives.³ Other relevant examples include trifluorobenzene metalation by *t*BuLi in the presence of TMSCl first reported by Gilman and reinvestigated by Schlosser, as well as Kondo's report on functionalizing electron-rich and electron-deficient arenes by employing *t*Bu-P4 base/electro-

^{(1) (}a) Do, H.-Q.; Daugulis, O. J. Am. Chem. Soc. 2007, 129, 12404. (b) Do, H.-Q.; Daugulis, O. J. Am. Chem. Soc. 2008, 130, 1128. (c) Do, H.-Q.; Khan, R. M. K.; Daugulis, O. J. Am. Chem. Soc. 2008, 130, 15185. (2) Review: (a) Slocum, D. W.; Shelton, P.; Moran, K. M. Synthesis. 2005, 3477. (b) Prakash, G. K. S.; Mathew, T.; Hoole, D.; Esteves, P. M.; Wang, Q.; Rasul, G.; Olah, G. A. J. Am. Chem. Soc. 2004, 126, 15770. (c) Deacon, G. B.; Smith, R. N. M. Aust. J. Chem. 1982, 35, 1587. (d) Hellmann, M.; Bilbo, A. J.; Pummer, W. J. J. Am. Chem. Soc. 1955, 77, 3650. (e) Mongin, F.; Marzi, E.; Schlosser, M. Eur. J. Org. Chem. 2001, 2771. (f) Burukin, A. S.; Vasil'ev, A. A.; Struchkova, M. I.; Kachala, V. V.; Zlotin, S. G. Russ. Chem. Bull. 2005, 54, 964. (g) Boga, C.; Del Vecchio, E.; Forlani, L.; Todesco, P. E. J. Organomet. Chem. 2000, 601, 233.

^{(3) (}a) Krizan, T. D.; Martin, J. C. J. Am. Chem. Soc. 1983, 105, 6155. (b) Taylor, S. L.; Lee, D. Y.; Martin, J. C. J. Org. Chem. 1983, 48, 4156. (c) Marsais, F.; Laperdrix, B.; Güngör, T.; Mallet, M.; Quéguiner, G. J. Chem. Res. Miniprint 1982, 2863. (d) In situ exhaustive halogenation of cyclopentadiene: Straus, F.; Kollex, L.; Heyn, W.; Kuhnel, R. Chem. Ber. 1930, 63B, 1868. (e) Tribromobenzene bromination by a mixture of tBuOK and tBuOBr: Mach, M. H.; Bunnett, J. F. J. Am. Chem. Soc. 1974, 96, 926

phile combinations.⁴ Several other groups have described similar methodologies with either silyl- or boryl-derived electrophiles.⁵ It appears, however, that in situ trapping has not been widely applied to arene halogenation.^{3d,e} Furthermore, potassium phosphate and *t*BuOLi have not been employed as metalating agents for such reactions. We report here a simple method for in situ halogenation of sp² C–H bonds in heterocycles and electron-deficient arenes under noncryogenic conditions.

Minor modifications of the copper-catalyzed arylation conditions allowed the development of an efficient process for in situ sp² C—H bond halogenation. The scope of the halogenation reaction is presented in Table 1. Electron-rich heterocycles such as benzothiazole, butylimidazole, and phenyloxazole can be chlorinated and brominated (entries 1—4). The halogenating reagent must be optimized for each case. Either carbon tetrahalides (entries 1—3) or dibromotetrafluoroethylene (entry 4) may be employed for electron-rich heterocycle halogenation.

Electron-deficient heterocycles such as pyridine *N*-oxide and 2-phenylpyridine *N*-oxide are brominated by employing a mixture of *t*BuOLi base and carbon tetrabromide (entries 5 and 6). For pyridine *N*-oxide, dihalogenation/reduction to the dibromopyridine product is obtained in a moderate yield (entry 6). Selective monohalogenation of pyridine *N*-oxide was not achieved under a variety of conditions. In contrast with the copper-catalyzed arylation process, halogenation is unsuccessful for pyridazine and pyrimidine, presumably due to their insufficient acidity. ⁶ Consequently, higher acidity is required for the halogenation reaction if it is compared to arylation. ⁷

Electron-deficient arenes can also be efficiently halogenated (entries 7–14). Pentachlorobenzene is iodinated in excellent yield by using a combination of iodine(I) chloride and *t*BuOLi in DMF (entry 7). Nitro and cyano groups are tolerated as shown in bromination of 3-nitrofluorobenzene (entry 8) and one-step tribromination of 3,5-difluorobenzonitrile (entry 9). For the latter substrate, selective monohalogenation could not be achieved. If acidic pentafluorobenzene is halogenated, even the weak K₃PO₄ base can be employed (entry 10), affording iodopentafluorobenzene in excellent yield. Previously, butyllithium has been used for pentafluorobenzene deprotonation-reaction with electrophiles sequences. Monoiodination of methoxytetrafluorobenzene and one-step diiodination of 1,2,4,5-tetrafluorobenzene af-

Table 1. Halogenation Scope^a

Arene K₃PO₄ or tBuOLi
Hal-X, 60-120 °C
DMF or DMF/xylenes

		reagent		
entry	arene	base	product	yield
1	N S	CCl₄ <i>t</i> BuOLi	S CI	80%
2	N S	CBr_4 K_3PO_4	N S Bu	82%
3	Bu N N	CBr₄ <i>t</i> BuOLi	Br N	91%
4		(BrCF ₂) ₂ <i>t</i> BuOLi	O Br	80%
5		CBr₄ <i>t</i> BuOLi	⊕ Br O ⊝	56%
6⁵	(N O O O O O O O O O O O O O O O O O O O	CBr₄ <i>t</i> BuOLi	Br N Br	30%
7	$C_{\epsilon}CI_{\epsilon}H$	ICI <i>t</i> BuOLi	CI	90%
8	NO ₂	CBr₄ <i>t</i> BuOLi	NO ₂ Br F CN	55%
9	F F	CBr₄ #BuOLi	Br Br F	40%
10	$C_{\varepsilon}F_{arsigma}H$	l₅ K₃PO₄	F F	85%
11	F F	l₂ <i>t</i> BuOLi	F—F	98%
12	F—F	l₂ <i>t</i> BuOLi	F—F	95%
13°	F	ICI <i>t</i> BuOLi	F_F	58%
14 ⁻¹	F	ICI <i>t</i> BuOLi	F	39%

 ^a Substrate (1 equiv), base (2-4 equiv), halogenating reagent (1.5-4 equiv). Yields are isolated yields. See Supporting Information for details.
 ^b m-Xylene solvent. ^c 1,3,5-Trifluorobenzene (3 equiv), ICl (1 equiv).
 ^b 1,3,5-Trifluorobenzene (1 equiv), ICl (4 equiv).

fords the corresponding halides in excellent yields (entries 11 and 12). 1,3,5-Trifluorobenzene can be either mono-

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^{(4) (}a) Dua, S. S.; Gilman, H. J. Organomet. Chem. 1974, 64, C1—C2. (b) Howells, R. D.; Gilman, H. Tetrahedron Lett. 1974, 15, 1319. (c) Schlosser, M.; Guio, L.; Leroux, F. J. Am. Chem. Soc. 2001, 123, 3822. (d) Imahori, T.; Kondo, Y. J. Am. Chem. Soc. 2003, 125, 8082. (e) Eaton, P. E.; Cunkle, G. T.; Marchioro, G.; Martin, R. M. J. Am. Chem. Soc. 1987, 100, 948

^{(5) (}a) Vazquez, E.; Davies, I. W.; Payack, J. F. *J. Org. Chem.* **2002**, 67, 7551. (b) Caron, S.; Hawkins, J. M. *J. Org. Chem.* **1998**, 63, 2054. (c) Kristensen, J.; Lysén, M.; Vedsø, P.; Begtrup, M. *Org. Lett.* **2001**, 3, 1435. (d) Black, W. C.; Guay, B.; Scheuermeyer, F. *J. Org. Chem.* **1997**, 62, 750

^{(6) (}a) Shen, K.; Fu, Y.; Li, J.-N.; Liu, L.; Guo, Q.-X. Tetrahedron 2007, 63, 1568. (b) Bordwell, F. G. Acc. Chem. Res. 1988, 21, 456.

⁽⁷⁾ A figure listing substrates not halogenated under these conditions is included in Supporting Information.

⁽⁸⁾ Review Burton, D. J.; Yang, Z.-Y.; Morken, P. A. *Tetrahedron* **1994**, *50*, 2993.

iodinated or triiodinated in acceptable yields depending on the ratio of arene to iodine(I) chloride (entries 13 and 14). 1,3-Dihalobenzenes are insufficiently acidic and are unreactive under these conditions. Attempted bromination of 1,3-dinitrobenzene resulted in about 10% conversion to the product. 1,3,5-Trinitrobenzene decomposes under the reaction conditions.

The halogenation of electron-deficient arenes most likely proceeds by an initial generation of an equilibrium concentration of the aryl anion followed by reaction with an electrophile. The lifetime of aryllithium and arylpotassium species must be short because significant amounts of benzyne-derived products are not formed.

At this point we are unsure about the exact structure of the electrophilic halogenating agent. It is conceivable that the reaction of *t*BuOLi with the halogen electrophile may produce a *tert*-butyl hypohalide. However, it is known that, at least for iododerivative, the structure of the hypohalide varies with the method of preparation. ¹⁰

In conclusion, we have developed a new method for in situ halogenation of acidic sp² carbon—hydrogen bonds in heterocycles and electron-deficient arenes. Either monohalogenation or one-step polyhalogenation is possible for substrates possessing several C—H bonds that are flanked by electron-withdrawing groups. For the most acidic substrates, such as pentafluorobenzene, K₃PO₄ base can be employed instead of the currently used BuLi for metalation/functionalization sequences.

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Supporting Information Available: Experimental details, data, and spectra for new compounds. This material is available free of charge via the Internet at http://pubs.acs.org.

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^{(9) (}a) Glover, S. A.; Goosen, A. Tetrahedron Lett. 1980, 21, 2005. (b)
Goosen, A.; McCleland, C. W. J. Chem. Soc. Perkin Trans. 1 1976, 383.
(10) Tanner, D. D.; Gidley, G. C.; Das, N.; Rowe, J. E.; Potter, A. J. Am. Chem. Soc. 1984, 106, 5261.